

## WASHING DEVICE FOR PACKAGING THE IMAGE

### BACKGROUND OF THE INVENTION

#### Field of the invention

The invention relates to a cleaning mechanism for an image sensor package,  
5 and in particular to a mechanism for efficiently and quickly cleaning an image  
sensor in package processes, so as to increase the production yield.

#### Description of the Related Art

Referring to FIG. 1, a conventional image sensor includes a substrate 10, a  
frame layer 18, a photosensitive chip 26, a plurality of wires 28, and a transparent  
10 layer 34. The substrate 10 has a first surface 12 on which a plurality of signal  
input terminals 15 is formed, and a second surface 14 on which a plurality of  
signal output terminals 16 is formed. The frame layer 18 has an upper surface 20  
and a lower surface 22 adhered to the first surface 12 of the substrate 10 to form a  
chamber 24 together with the substrate 10. The photosensitive chip 26 is arranged  
15 within the chamber 24 and is mounted to the first surface 12 of the substrate 10.  
Each wire 28 has a first terminal 30 and a second terminal 32. The first terminals  
30 are electrically connected to the photosensitive chip 26, and the second  
terminals 32 are electrically connected to the signal input terminals 15 of the  
substrate 10. The transparent layer 34 is adhered to the upper surface 20 of the  
20 frame layer 18.

In order to finish the above-mentioned package processes, the chamber 24

of the substrate 10 has to be efficiently cleaned, so as to decrease the particle.

Please refer to FIG. 2, is a traditional method of cleaning mechanism for an image sensor package includes a body element 40, a rotating device 42, and a cleaning device 44.

5       The body element 40 is formed with a chamber 46. The rotating device 42 is arranged within the chamber 46 of the body element 40. The cleaning device 44 is arranged within the chamber 46 of the body element 40 and is located on the upper end of the body element 40. So as to while the substrate 10 formed with frame layer 18 mounted on the rotating device 42, the chamber 24 of the substrate  
10   10 is faced the cleaning mechanism 44, respectively, the cleaner of the cleaning mechanism 44 is to clean the chamber 46 of the substrate 10.

However, the conventional cleaning mechanism for cleaning an image sensor package has following drawbacks.

1. Since a right angle is formed between the substrate 10 and frame layer 18,  
15   so particle is easily hide in the right angle, thus, cleaner can not efficiently clean the chamber 24.

## SUMMARY OF THE INVENTION

An object of the invention is to provide a cleaning mechanism for an image sensor package, wherein the processes for packaging an image sensor may be  
20   efficiently cleaned, so as to increase the production yield.

To achieve the above-mentioned object, the invention provides a cleaning

mechanism for an image sensor package, the cleaning mechanism is for cleaning the substrate and the frame layer arranged on the substrate of the image sensor to form a chamber between the frame layer and the substrate. The mechanism includes a seal up body is formed with a cleaning room. A rotating device is  
5 located within the cleaning room of the seal up body. The substrate formed with a frame layer is fixed on the rotating device, then, the chamber of the substrate is faced the centrifugal force direction from the rotating device. A cleaning device is mounted on the side of the cleaning room of the seal up body, and is cleaned the chamber of the substrate by cleaner.

## 10                    **BRIEF DESCRIPTION OF THE DRAWINGS**

FIG. 1 is a cross-sectional view showing a conventional image sensor package.

FIG. 2 is a schematic illustrated showing a conventional cleaning mechanism for an image sensor package.

15                    FIG. 3 is a schematic illustrated showing a cleaning mechanism for an image sensor package of the present invention.

FIG. 4 is a cross-sectional view showing a cleaning mechanism for an image sensor package of the present invention.

## **DETAILED DESCRIPTION OF THE INVENTION**

20                    Please refer to FIG. 3. A cleaning mechanism for an image sensor of the present invention includes a seal up body 50, a rotating device 52, and a cleaning

mechanism54.

The seal up body 50 has a lower element 56, a periphery wall 58, and a  
upped cover 60 to form a chamber 62.

The rotating device 52 is located within the cleaning room of the seal up  
5 body, and arranged on the lower element 56.

The cleaning device 54 is located within the cleaning room 62 of the seal up  
body50, and mounted on the periphery wall 58 of the cleaning room 62 of the seal  
up body50, the cleaning device54 may be ejected the cleaner. In the embodiment,  
the cleaner is water or N2 or CO2.

10 Please refer to FIG. 4, is a cross-sectional schedule showing a cleaning  
mechanism for an image sensor package. A substrate 64 is formed with a frame  
layer 66 for an image sensor package. A chamber 68 is formed between the  
substrate 64 and frame layer 66. The substrate 64 is located within the cleaning  
room 62, and is mounted on the rotating device 52, the chamber 68 is faced the  
15 periphery wall 58 of the cleaning device 50. Therefore, the cleaner from the  
cleaning device 54 is ejected to the chamber 68, so that may be cleaned the  
chamber68 by cleaner and centrifugal force from the rotating device 52.

While the invention has been described by way of an example and in terms  
of a preferred embodiment, it is to be understood that the invention is not limited  
20 to the disclosed embodiment. To the contrary, it is intended to cover various  
modifications. Therefore, the scope of the appended claims should be accorded

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the broadest interpretation so as to encompass all such modifications.